	L #	Hits	S arch T xt	DBs
1	L2	16826	((inkjet$4 or (fluid or ink or liquid) near3 (jet$4 or eject$)) with (printhead or printer or head or nozzle or orifice)).ti,ab.	US-PGPUB; USPAT
2	L4	69635	(photoresist or resist or photosensitiv$8 or photopolymer$8 or (photo or light or uv or ultraviolet or radiat$8 or irradiat$8) near3 (sensitiv$8 or polymer or polymeris$8 or polymeriz$8 or crosslink$8 or cross adj link$8)).ti,ab.	US-PGPUB; USPAT
3	L5	311	2 and 4	US-PGPUB; USPAT
4	L6	924055	(metal$8 or conduct$8 or circuit$4).ti,ab.	US-PGPUB; USPAT
5	L7	74	5 and 6	US-PGPUB; USPAT
6	L8	6295	sacrific$8.ti,ab.	US-PGPUB; USPAT
7	L9	9	5 and 8	US-PGPUB; USPAT
8	L10	34264	((substrate or support or base) near5 (depart$6 or detach$6 or remov$6 or strip$6 or peel$6)).ti,ab.	US-PGPUB; USPAT
9	L11	14	5 and 10	US-PGPUB; USPAT
10	L12	1057	430/320.ccls.	US-PGPUB; USPAT
11	L13	64	2 and 12	US-PGPUB; USPAT
12	L14	62	13 not (7 or 9 or 11)	US-PGPUB; USPAT
13	L20	793	347/47.ccls.	US-PGPUB; USPAT

	L #	Hits	Search Text	DBs
14	L21	42	4 and 20	US-PGPUB; USPAT
15	L22	28	21 not (7 or 9 or 11 or 13)	US-PGPUB; USPAT
16	L23	366875	((substrate or support or base) near5 (depart$6 or detach$6 or remov$6 or strip$6 or peel$6))	US-PGPUB; USPAT
17	L24	543706	(photoresist or resist or photosensitiv$8 or photopolymer$8 or (photo or light or uv or ultraviolet or radiat$8 or irradiat$8) near3 (sensitiv$8 or polymer or polymeris$8 or polymeriz$8 or crosslink$8 or cross adj link$8))	US-PGPUB; USPAT
18	L25	27235	23 same 24	US-PGPUB; USPAT
19	L26	3238483	(metal$8 or conduct$8 or circuit$4)	US-PGPUB; USPAT
20	L27	9883	25 same 26	US-PGPUB; USPAT
21	L28	74	(2 or 20) and 27	US-PGPUB; USPAT
22	L29	1862	Huang-Chi$.in.	US-PGPUB; USPAT
23	L30	468	chen-chia$.in.	US-PGPUB; USPAT
24	L31	122	chuang-yu$.in.	US-PGPUB; USPAT
25	L32	1	lion-jian$.in.	US-PGPUB; USPAT
26	L33	117	liu-chien$.in.	US-PGPUB; USPAT

	L #	Hits	Search Text	DBs
27	L34	1343	chen-chun$.in.	US-PGPUB; USPAT
28	L35	3870	(29 or 30 or 31 or 32 or 33 or 34)	US-PGPUB; USPAT
29	L36	21	2 and 35	US-PGPUB; USPAT
30	L37	98743	((inkjet$4 or (fluid or ink or liquid) near3 (jet$4 or eject$)) with (printhead or printer or head or nozzle or orifice))	EPO; JPO; DERWENT; IBM_TDB
31	L38	464704	(photoresist or resist or photosensitiv$8 or photopolymer$8 or (photo or light or uv or ultraviolet or radiat$8 or irradiat$8) near3 (sensitiv$8 or polymer or polymeris$8 or polymeriz$8 or crosslink$8 or cross adj link$8))	EPO; JPO; DERWENT; IBM_TDB
32	L39	5489205	(metal$8 or conduct$8 or circuit$4)	EPO; JPO; DERWENT; IBM_TDB
33	L40	176693	((substrate or support or base) near5 (depart$6 or detach$6 or remov$6 or strip$6 or peel$6))	EPO; JPO; DERWENT; IBM_TDB
34	L41	2653	37 and 38	EPO; JPO; DERWENT; IBM_TDB
35	L42	682	41 and 39	EPO; JPO; DERWENT; IBM_TDB

	L #	Hits	Search T xt	DBs
36	L43	67	40 and 42	EPO; JPO; DERWENT; IBM_TDB
37	L44	20849	sacrific$8	EPO; JPO; DERWENT; IBM_TDB
38	L45	24	41 and 44	EPO; JPO; DERWENT; IBM_TDB

	L #	Hits	Search T xt	DBs
1	L1	8647	((inkjet$4 or (fluid or ink or liquid) near3 (jet$4 or eject$4)) with (printhead or printer or head or nozzle or orifice)).clm.	US-PGPUB
2	L2	31634	(photoresist or resist or photosensitiv$8 or photopolymer$8 or (photo or light or uv or ultraviolet or radiat$8 or irradiat$8) near3 (sensitiv$8 or polymer or polymeris$8 ro polymeriz$8 or crosslink$8 or cross adj link$8)).clm.	US-PGPUB
3	L3	328348	(metal$8 or conduct$8 or circuit$4).clm.	US-PGPUB
4	L4	23200	((substrate or support or base) near5 (depart$6 or detach$8 or remov$6 or strip$6 or peel$8)).clm.	US-PGPUB
5	L5	35	1 and 2 and 3 and 4	US-PGPUB